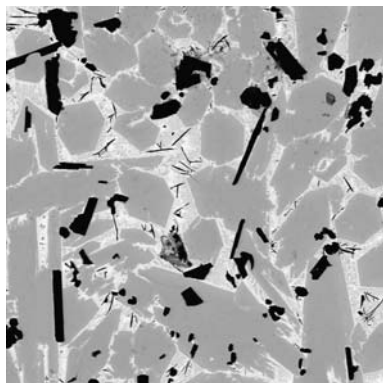




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CONTENTS

Editorial	1198
----------------------------	------



K. I. Schiffmann

Nanoindentation creep and stress relaxation tests of polycarbonate: Analysis of viscoelastic properties by different rheological models. . .	1199
---	------

D. A. Lucca, K. Herrmann, M. J. Klopstein, F. Menelao

Investigation of SiO ₂ thin films on Si substrates for use as standards for laser-acoustic measuring devices	1212
--	------

V. Linss, T. Chudoba

Determination of the critical tensile stress of sapphire by spherical indentation with additional lateral forces	1216
---	------

B. Yang, H. Vehoff, R. Hempelmann

The deformation behaviour of electrodeposited nanocrystalline Ni in an atomic force microscope with a newly developed in situ bending machine	1220
--	------

A. Barnoush, H. Vehoff

In situ electrochemical nanoindentation of a nickel (111) single crystal: hydrogen effect on pop-in behaviour	1224
--	------

L. Largeau, G. Patriarche, E. Le Bourhis, J.-P. Rivière

Indentation behaviour of (011) thin films of III–V semiconductors: polarity effect differences between GaAs and InP	1230
--	------

M. Olek, K. Kempa, M. Giersig

Multiwall carbon nanotubes-based composites – mechanical characterization using the nanoindentation technique.	1235
---	------

D. Denkwicz, S. Landis, L. Ratajczyk, Z. Rymuza

Nanoindentation studies of stamp materials for nanoimprint lithography	1239
--	------

A. Markström, S. Norgren, K. Frisk, B. Jansson, T. Sterneland

Experimental and thermodynamic evaluation of the Co–Cr–C system	1243
---	------



M. Arita

Thermodynamics of high-temperature cuprous sulfide	1251
--	------

B. Matovic, G. Rixecker, S. Boskovic, F. Aldinger

Sintering of Si ₃ N ₄ with Li-exchanged zeolite additive	1264
--	------

B. Matovic, G. Rixecker, S. Boskovic, F. Aldinger

Effect of LiYO ₂ addition on sintering behavior and indentation properties of silicon nitride ceramics	1268
--	------

K. Piel

Mechanism of quasi-viscous flow of zinc single crystals	1273
---	------

H. Brodowsky, Q. Chen, Z. Xiao, Z. Yin

The absolute thermoelectric power of chromium, molybdenum, and tungsten.	1279
---	------

S. M. H. Mirbagheri

Modelling of metal–mould interface resistance in the Al-11.5 wt.% Si alloy casting process.	1285
--	------

Kösterpreis	1295
------------------------------	------

Notifications

Personal.	1296
Conferences	1297
Imprint	1298